

**IN THE SPECIFICATION:**

Please replace the paragraph at page 16, lns. 23-28 with the following amended paragraph:

Reference numeral 46 denotes a pixel electrode (EL element anode) made from a transparent conducting film. After opening a contact hole in the second passivation film 45, in the second interlayer insulating film 44 and in the first passivation film 41, the pixel electrode [[45]] 46 is formed so as to be connected to the drain wiring 37 of the current control TFT 202.

Please replace the paragraph at page 32, ln. 29 - page 33, ln. 6 with the following amended paragraph:

The pixel electrode 349 becomes directly connected to an organic material such as the EL layer (emitting layer) or a charge transporting layer, and therefore it is possible for the mobile ions contained in the EL layer to diffuse throughout the pixel electrode. In other words, without connecting the pixel electrode [[348]] 349 directly to the drain region 331, a portion of the active layer, the introduction of mobile ions into the active layer due to the drain wiring 343 being interrupted can be prevented in the structure of embodiment 1.